

# How to simulate the photogating effect in InAs nanowire phototransistors?

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08 September, 2015



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# 1. Majority carrier dominated InAs NWs near-infrared detector

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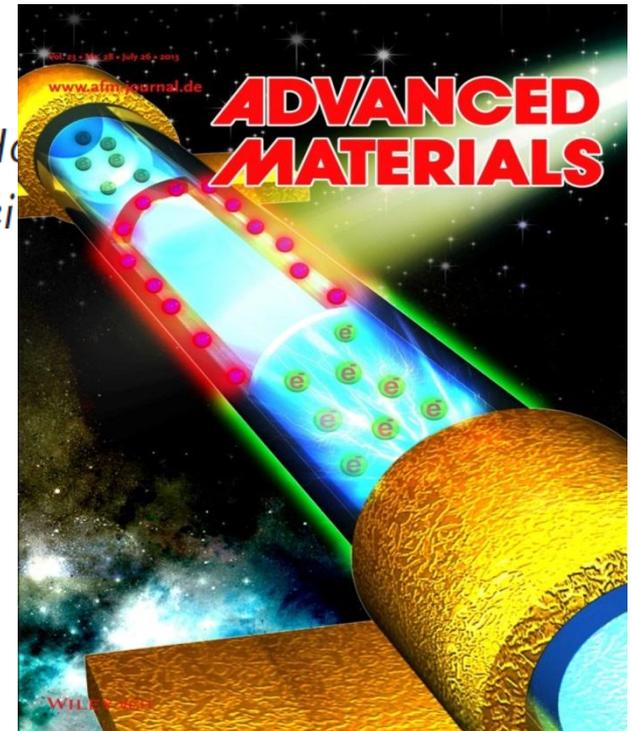
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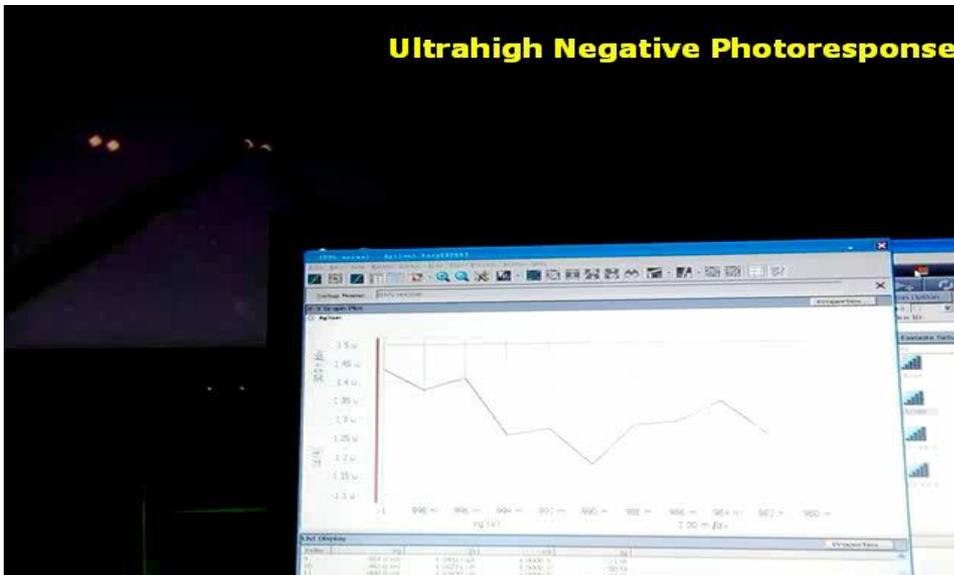
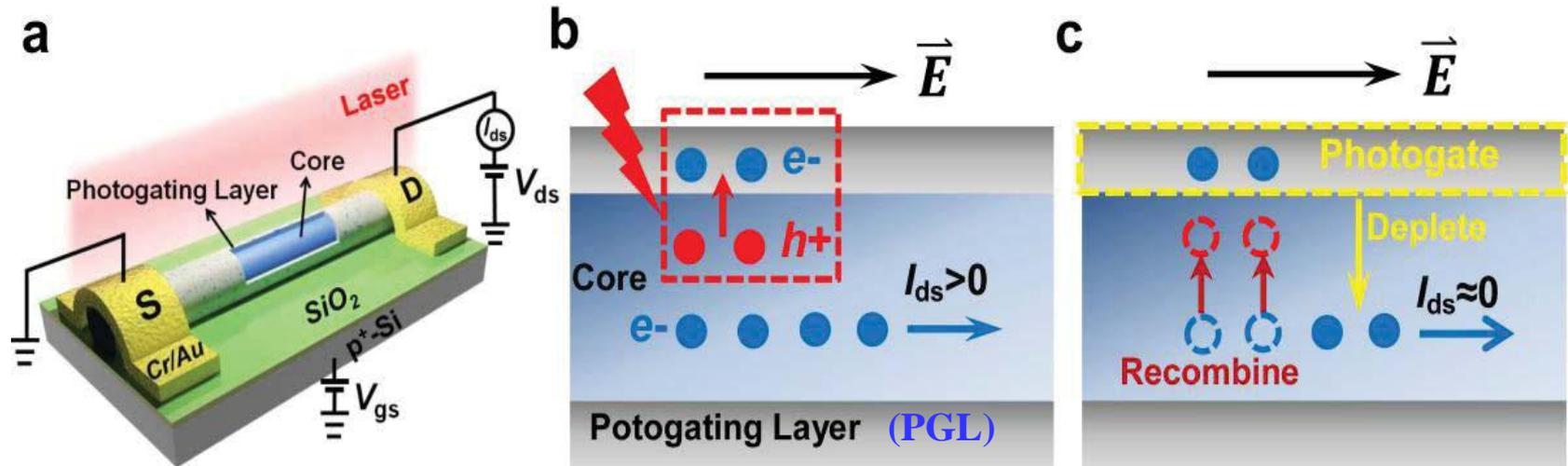
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## Anomalous and Highly Efficient InAs Nanowire Phototransistors Based on Majority Carrier Transport at Room Temperature

Nan Guo, Weida Hu,\* Lei Liao,\* SenPo Yip, Johnny C. Ho, Jin Zou, Tao Jiang, Shiwei Wu, Xiaoshuang Chen, and Wei



# 1. Majority carrier dominated InAs NWs near-infrared detector



The majority carrier is manipulated by photogating effect, leading to an anomalous photodetection

# 1. Majority carrier dominated InAs NWs near-infrared detector

Electrons trapped for a much longer time by PGL

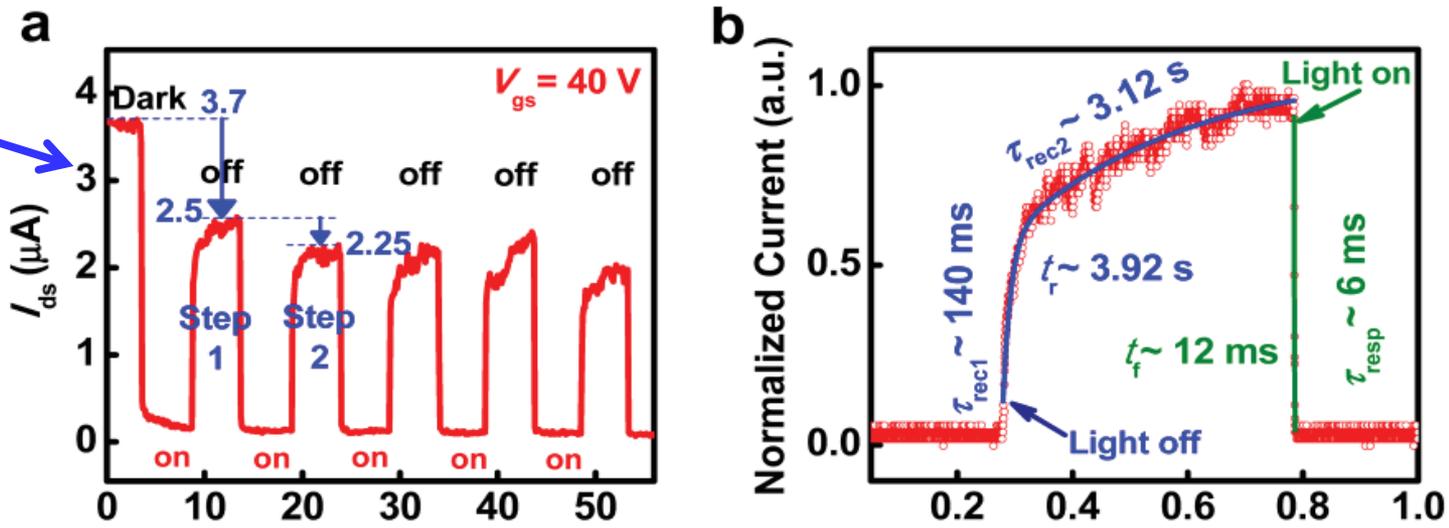
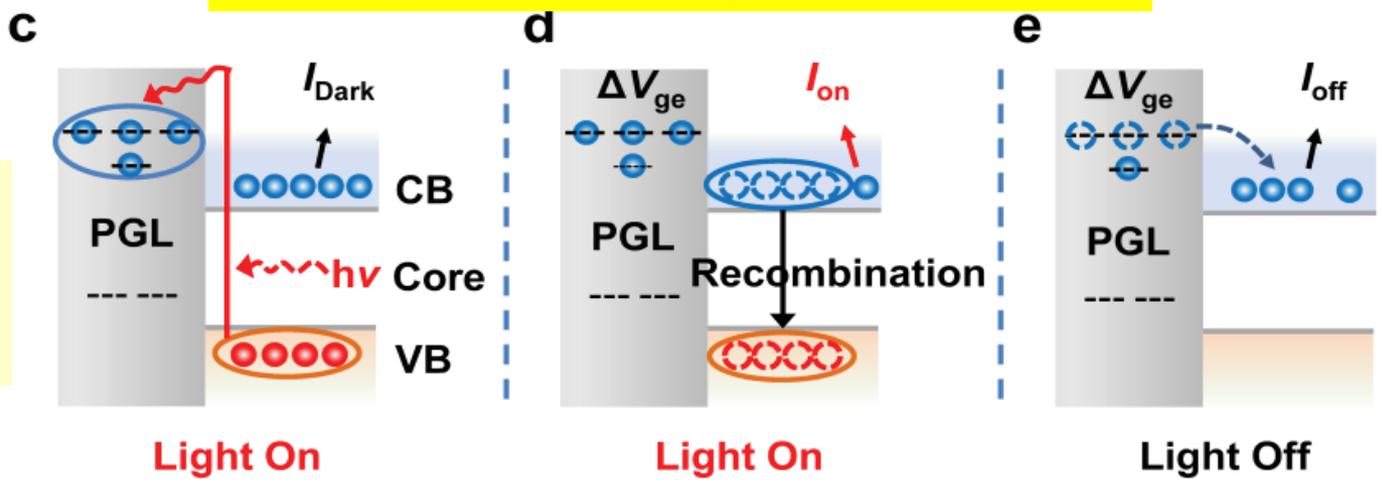


Photo gain  $\sim 10^5$ , Response time 12 ms

Anomalous photodetector based on the majority carrier



## 2. Single InAs NWs near-infrared detector

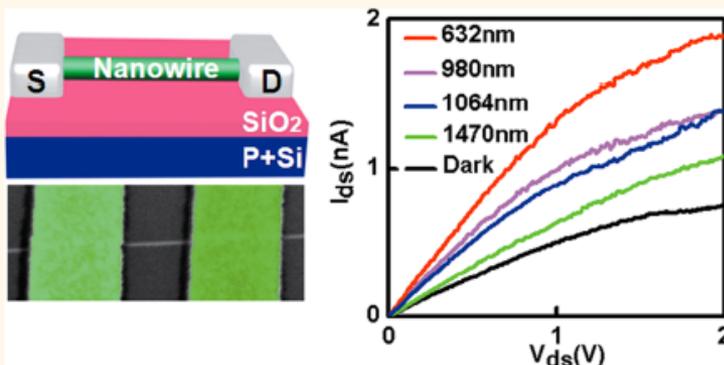
# Single InAs Nanowire Room-Temperature Near-Infrared Photodetectors



Jinshui Miao,<sup>†,#</sup> Weida Hu,<sup>†,#,\*</sup> Nan Guo,<sup>†,#</sup> Zhenyu Lu,<sup>†,#</sup> Xuming Zou,<sup>‡</sup> Lei Liao,<sup>‡,\*</sup> Suixing Shi,<sup>†,#</sup> Pingping Chen,<sup>†,#</sup> Zhiyong Fan,<sup>§</sup> Johnny C. Ho,<sup>⊥</sup> Tian-Xin Li,<sup>†,#</sup> Xiao Shuang Chen,<sup>†,#,\*</sup> and Wei Lu<sup>†,#</sup>

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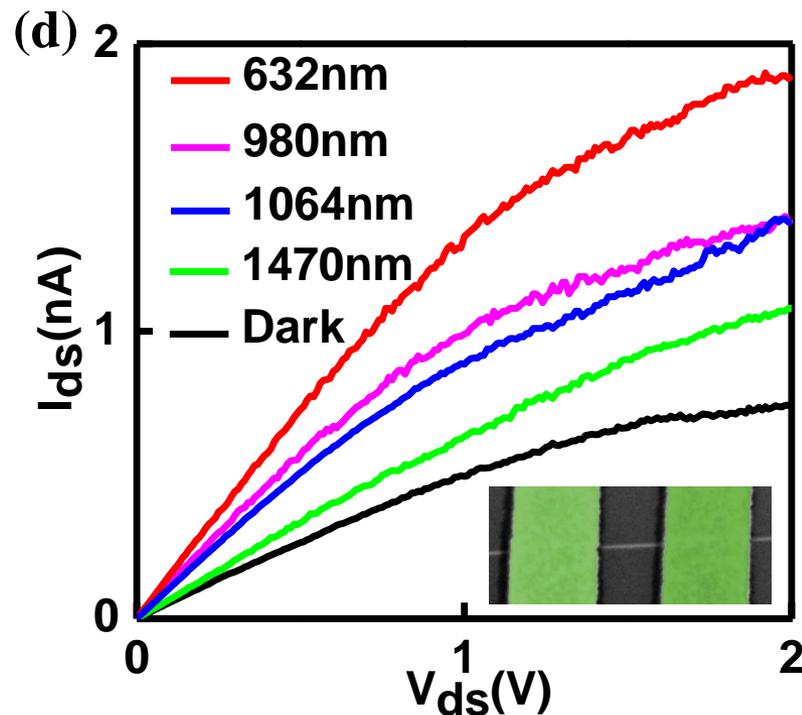
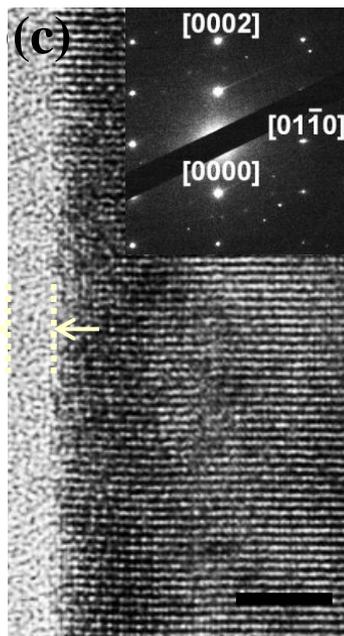
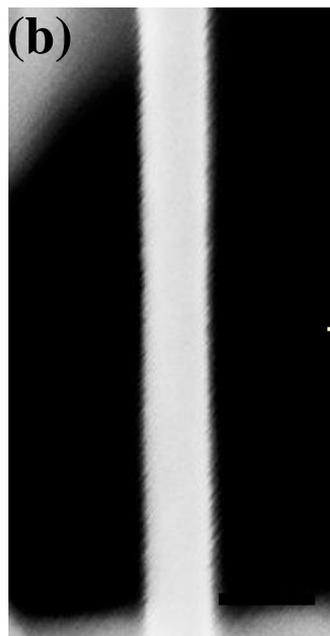
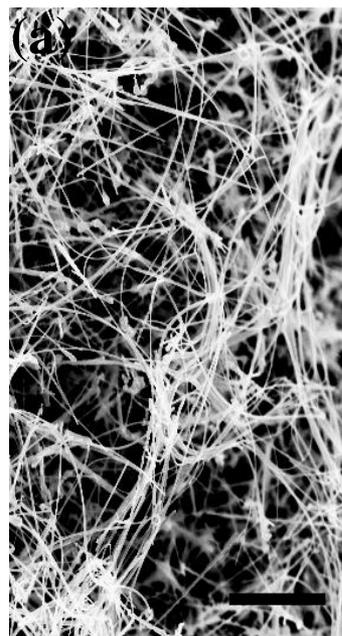
**ABSTRACT** Here we report InAs nanowire (NW) near-infrared photodetectors having a detection wavelength up to  $\sim 1.5 \mu\text{m}$ . The single InAs NW photodetectors displayed minimum hysteresis with a high  $I_{\text{on}}/I_{\text{off}}$  ratio of  $10^5$ . At room temperature, the Schottky–Ohmic contacted photodetectors had an external photoresponsivity of  $\sim 5.3 \times 10^3 \text{ AW}^{-1}$ , which is  $\sim 300\%$  larger than that of Ohmic–Ohmic contacted detectors ( $\sim 1.9 \times 10^3 \text{ AW}^{-1}$ ). A large enhancement in photoresponsivity ( $\sim 300\%$ ) had also been achieved in metal Au-cluster-decorated InAs NW photodetectors due to the formation of Schottky



J. S. Miao, Weida Hu\* et al. ACS Nano, 8, 3628 (2014)

## 2. Single InAs NWs near-infrared detector

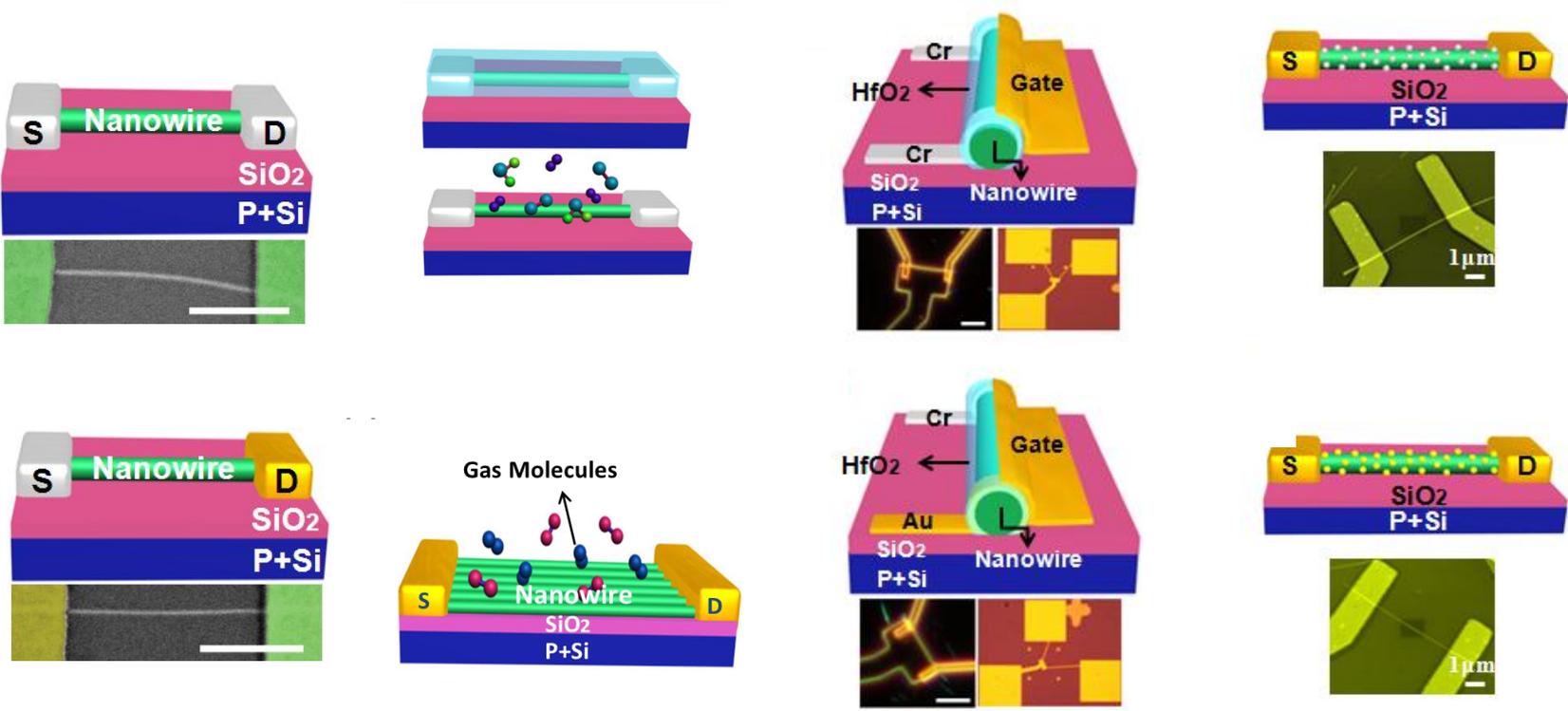
### Single-crystalline



SEM shows length 10 $\mu$ m, diameter 50 nm

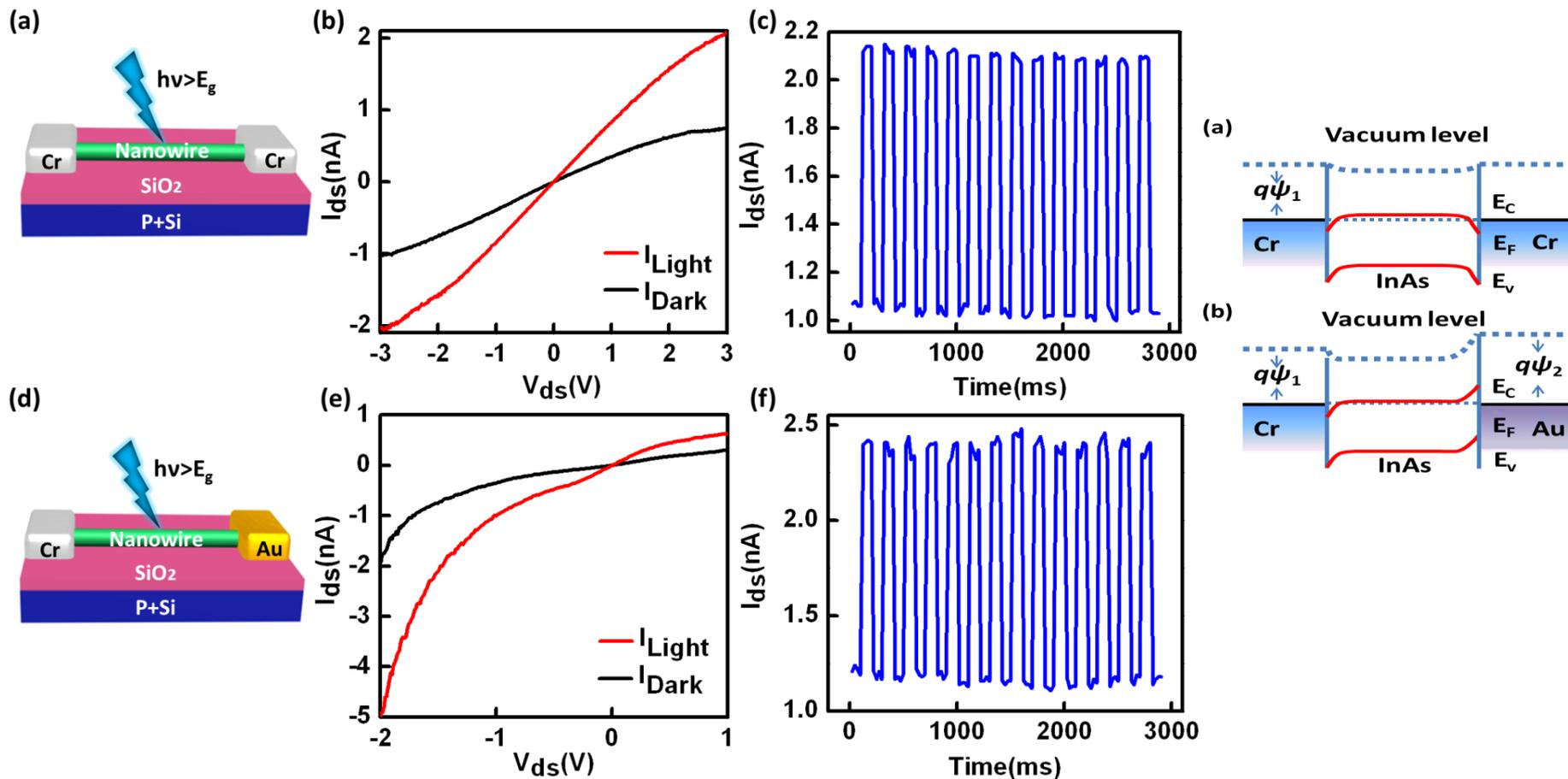
Photocurrent spectrum ranging from visible to near-infrared light. Detectors have distinct photoresponse.

# 2. Single InAs NWs near-infrared detector

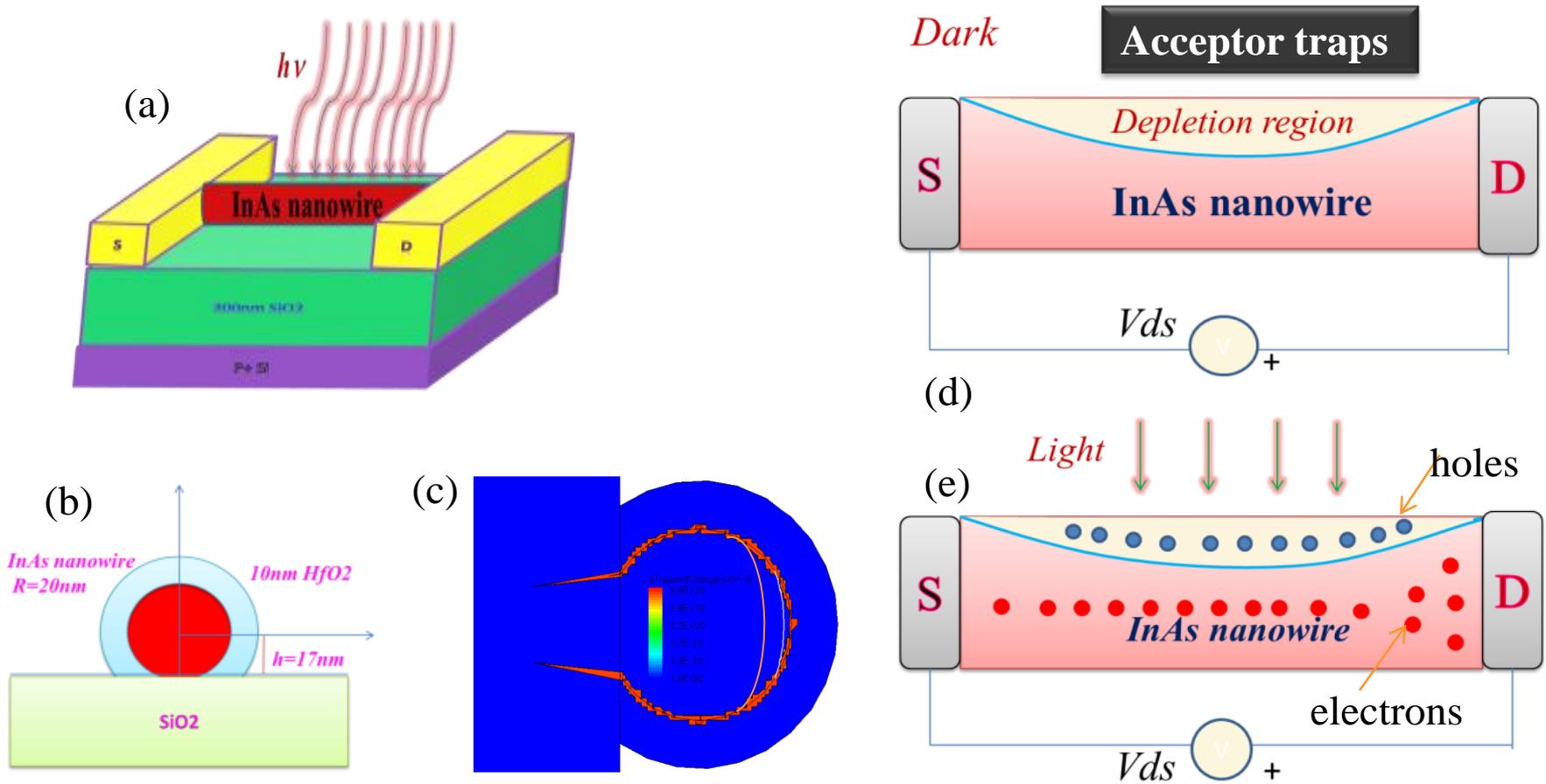


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## 2. Single InAs NWs near-infrared detector

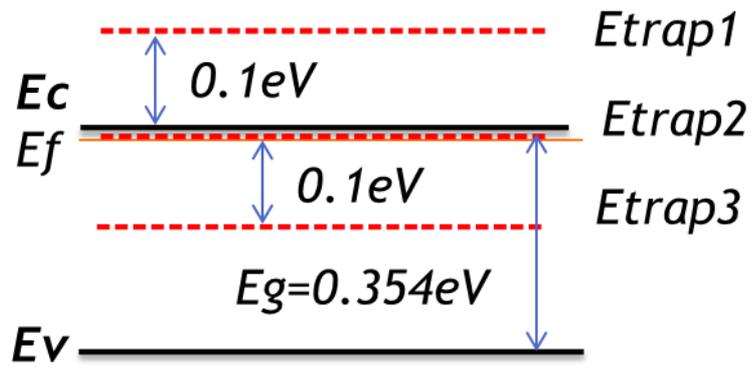
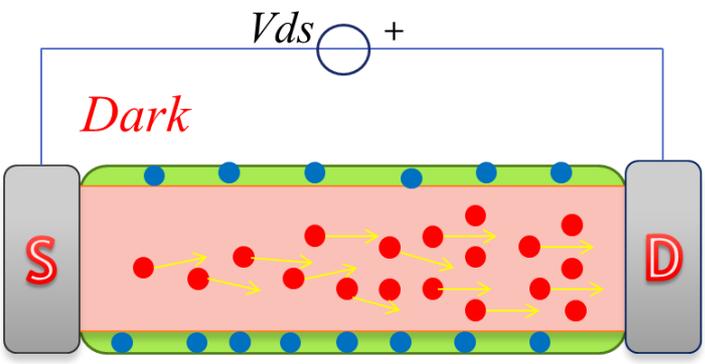


**Time-resolution: Short photoresponse time (~ms)**

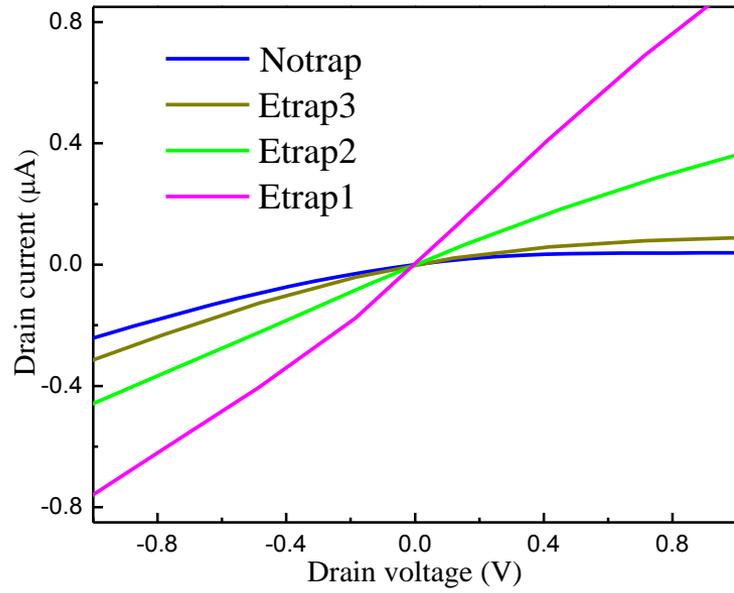
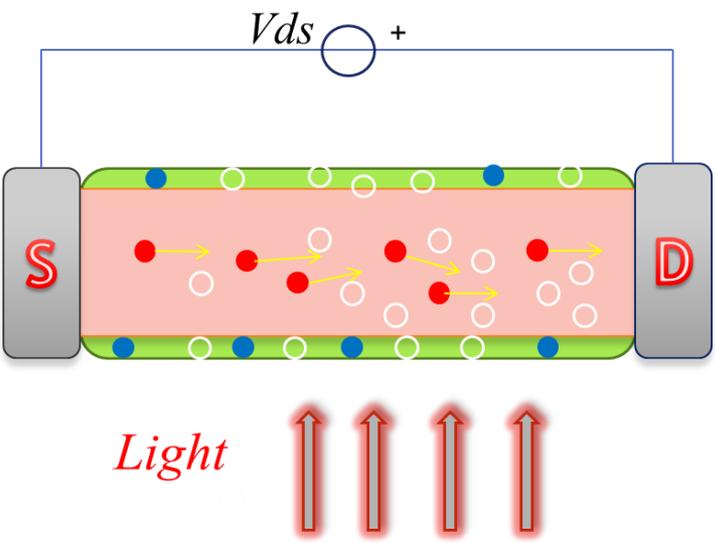


**Surface acceptor traps** which lead to a surface depletion will result in a positive photoresponse output. The mid band gap acceptor states at the InAs surface result in the trapping of majority carriers and surface depletion (Figure c) that causes band bending and a radial “gate” field (Figure d,e). Due to the gate field, photo generated holes are swept to the surface, where they recombine with trapped electrons, in effect modulating the gate field, while electrons are confined to the center of the nanowire.

**Donor traps**

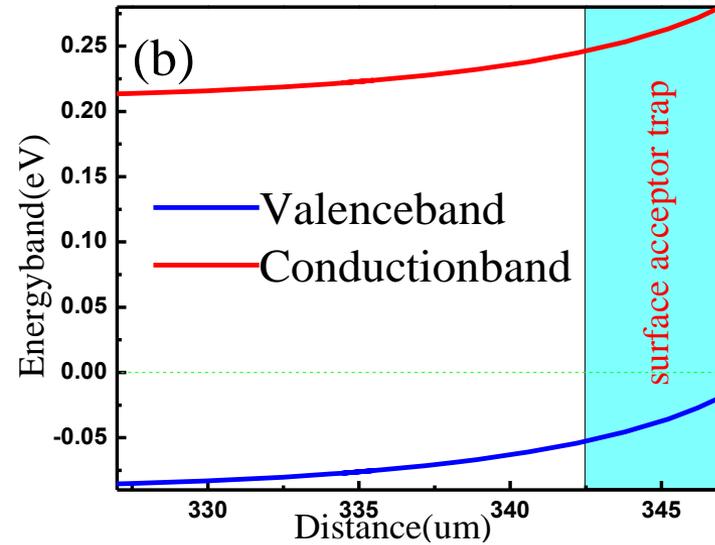
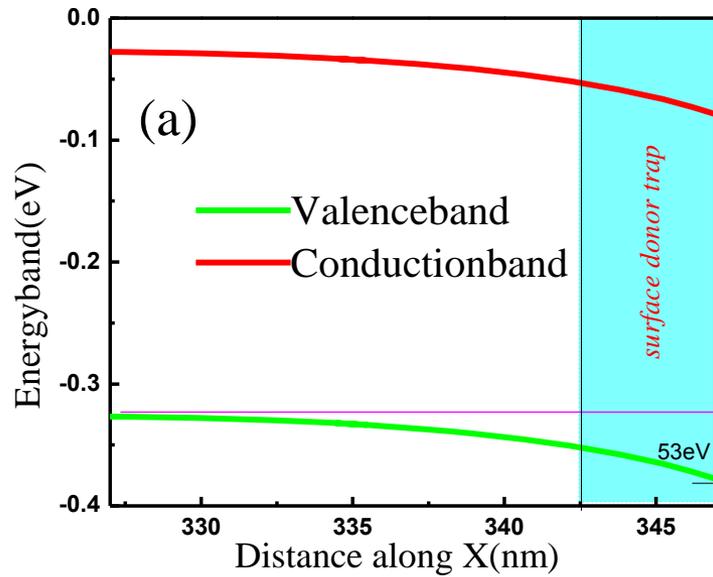


$E_{trap1} = E_c + 0.1eV$ ;  
 $E_{trap2} = E_c$ ;  
 $E_{trap3} = E_c - 0.1eV$ .



**Surface donor traps will result in a negative photoresponse output**

Duo to the high density of surface states located far from the conduction band contributed large number of ionization carriers, and the negative conductive gain can illustrated as that the photogenerated carriers are combined with these ionization carriers before being collected by electrodes.



*Questions*

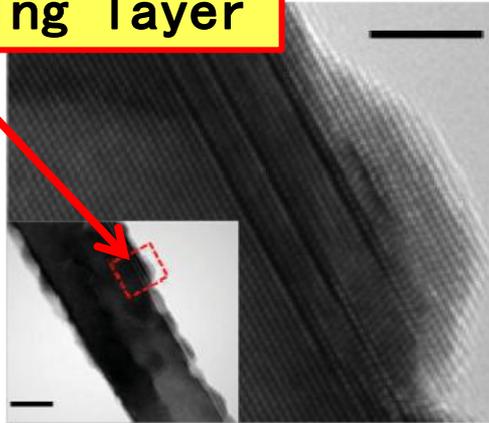
- Acceptor and donor traps?
- Transient response?

# Thank you for your attention!

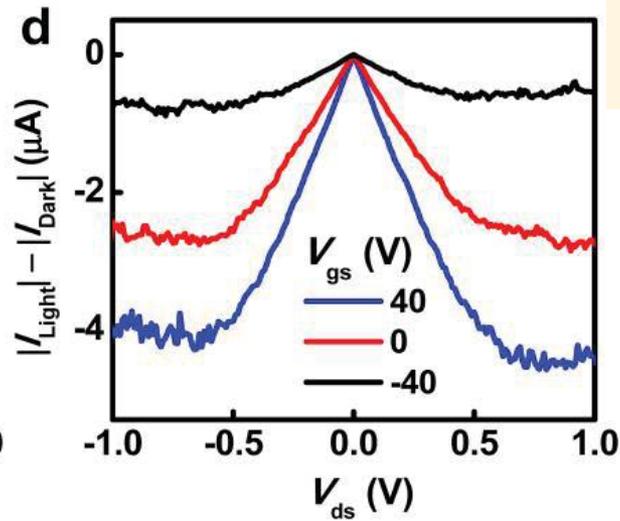
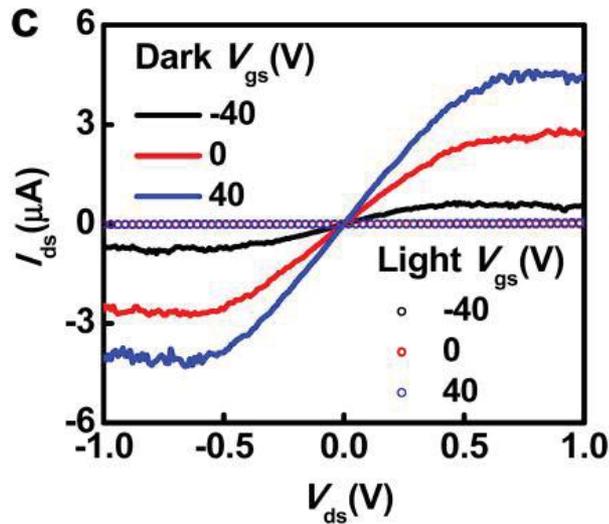
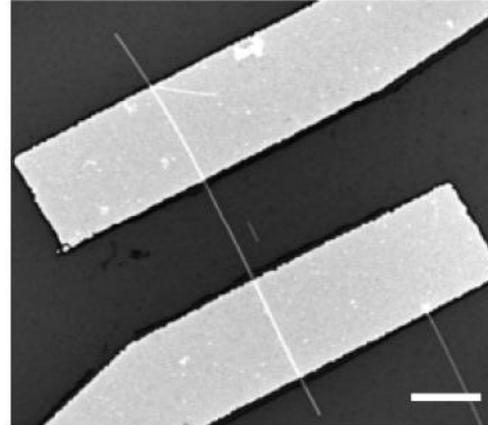


# 1. Majority carrier dominated InAs NWs near-infrared detector

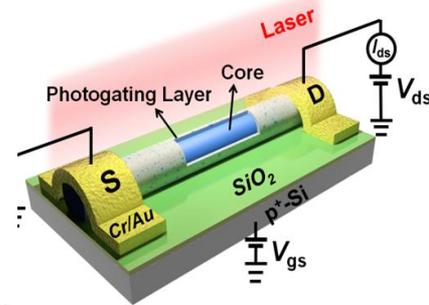
Photo gating layer



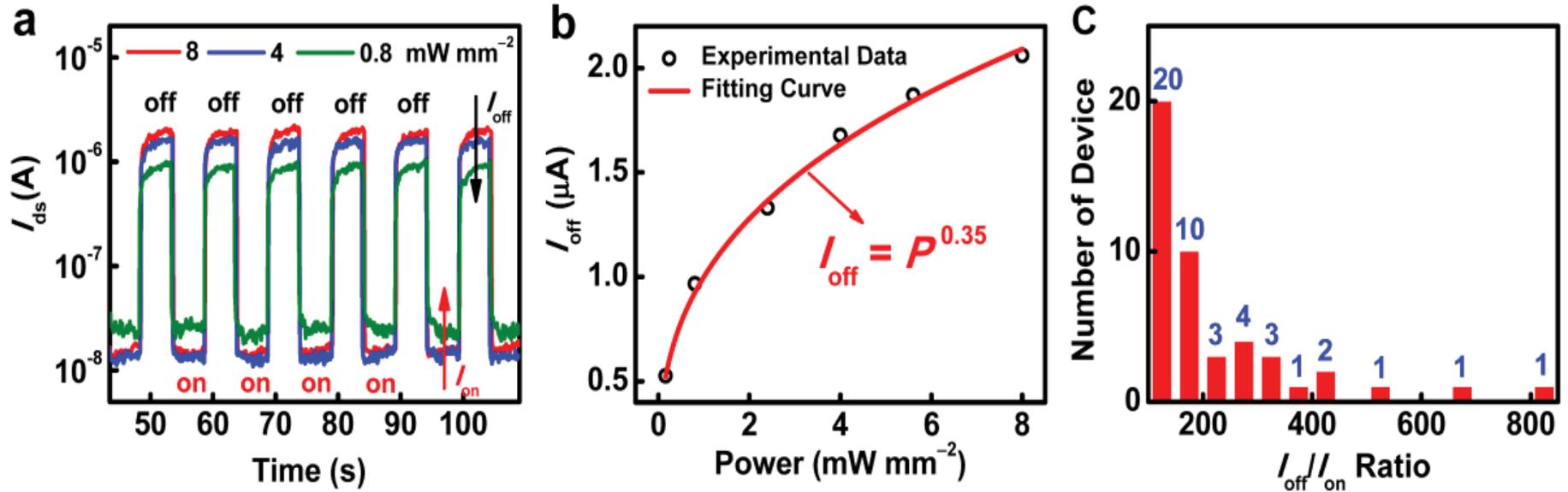
b



1D Photo gating effect strongly modulated by Back Gate

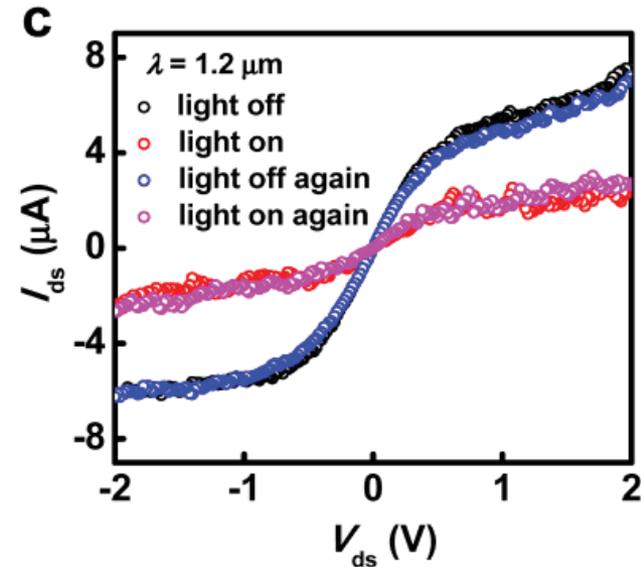
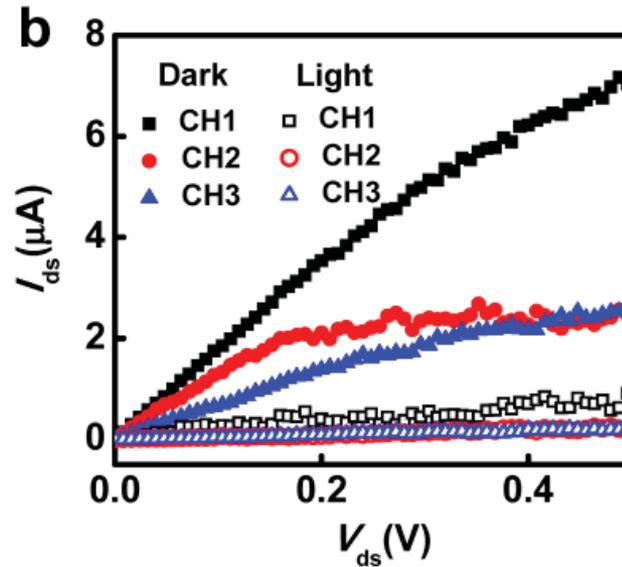
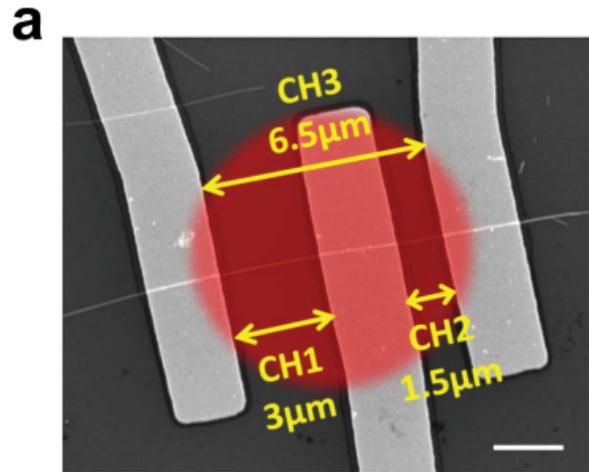


# 1. Majority carrier dominated InAs NWs near-infrared detector



$I_{off}$  satisfies the power law, proving that  $I_{off}$  originates from photoexcited carriers

# 1. Majority carrier dominated InAs NWs near-infrared detector



1D is superior to 2D

Infrared light: 1.2  $\mu\text{m}$   
Photo gain -1.1